

***Supporting Information***

**Tuning the Seebeck Effect in C<sub>60</sub>-based Hybrid Thermoelectric Devices through  
Temperature-dependent Surface Polarization and Thermally-modulated Interface  
Dipoles**

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## 1. The XRD patterns of the oxide film on ITO glass

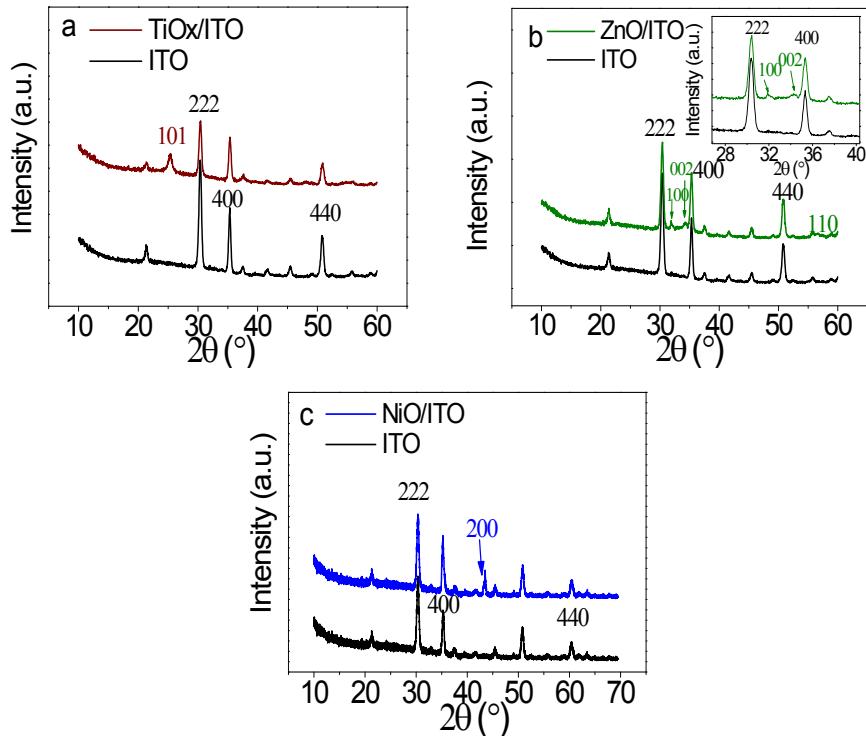


Figure S1: the XRD patterns of the oxide film prepared from the solution method: (a) $\text{TiO}_x$ , (b)  $\text{ZnO}$ , (c)  $\text{NiO}$ . The black line is the XRD for ITO glass substrate.

## 2. The work function of the oxide film measured by Kelvin Probe

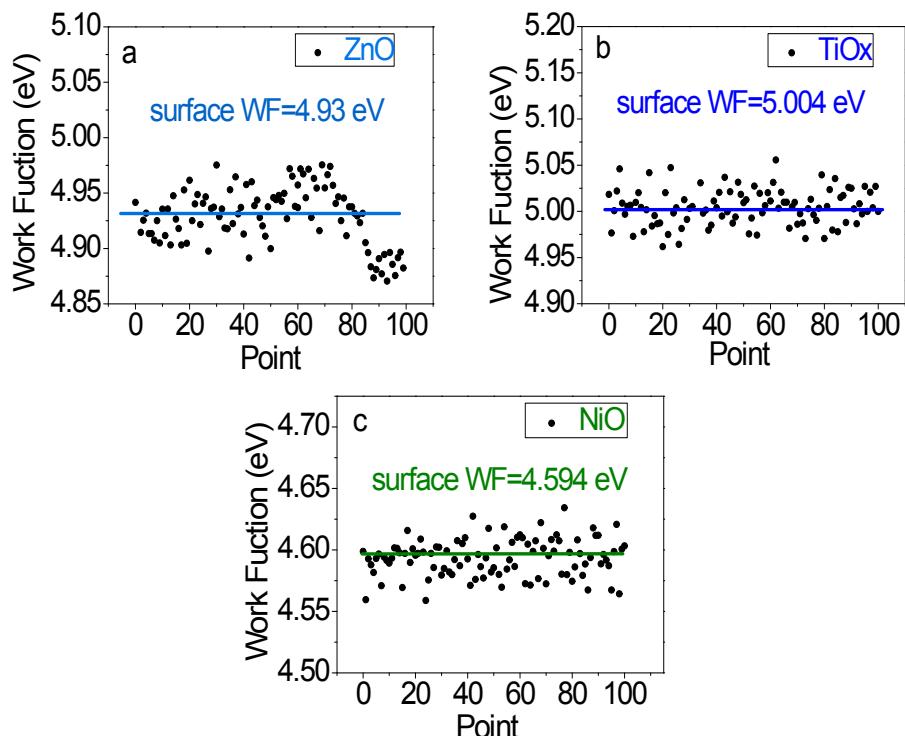


Figure S2: the work function (a) $\text{TiO}_x$ , (b)  $\text{ZnO}$ , (c)  $\text{NiO}$ , measured from Kelvin Probe at room temperature:

### 3. The thermovoltage as a function of temperature difference in the thin-film devices

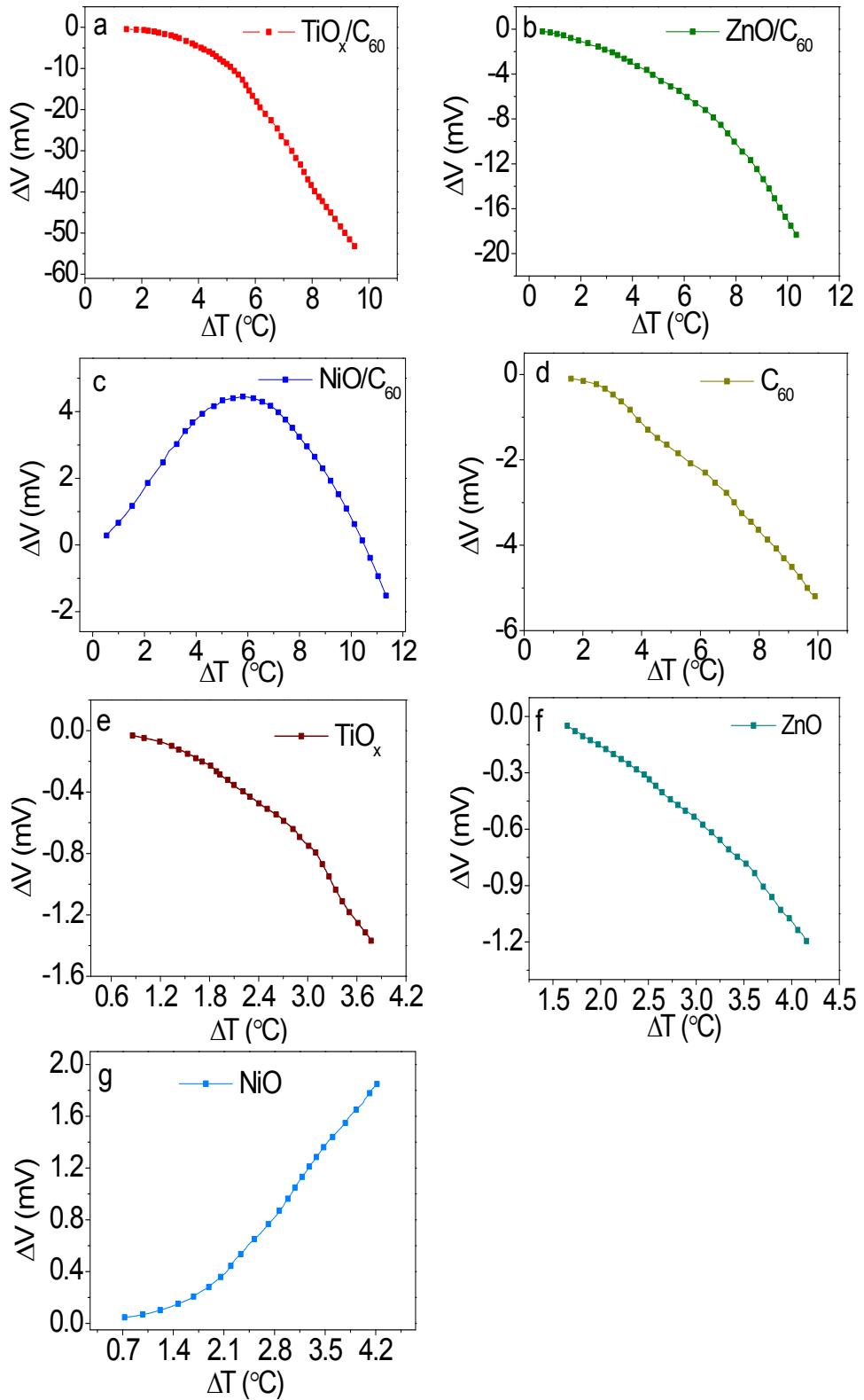


Figure S3: The thermovoltage as a function of temperature difference in the thin-film devices of (a) ITO/TiO<sub>x</sub>/C<sub>60</sub>/Al, (b) ITO/ZnO/C<sub>60</sub>/Al, (c) ITO/NiO/C<sub>60</sub>/Al (d) ITO/C<sub>60</sub>/Al, (e) ITO/TiO<sub>x</sub>/Al, (f) ITOZnO/Al, (g) ITO/NiO/Al.

#### 4. The temperature dependence of electrical conductivity in the single-layer devices

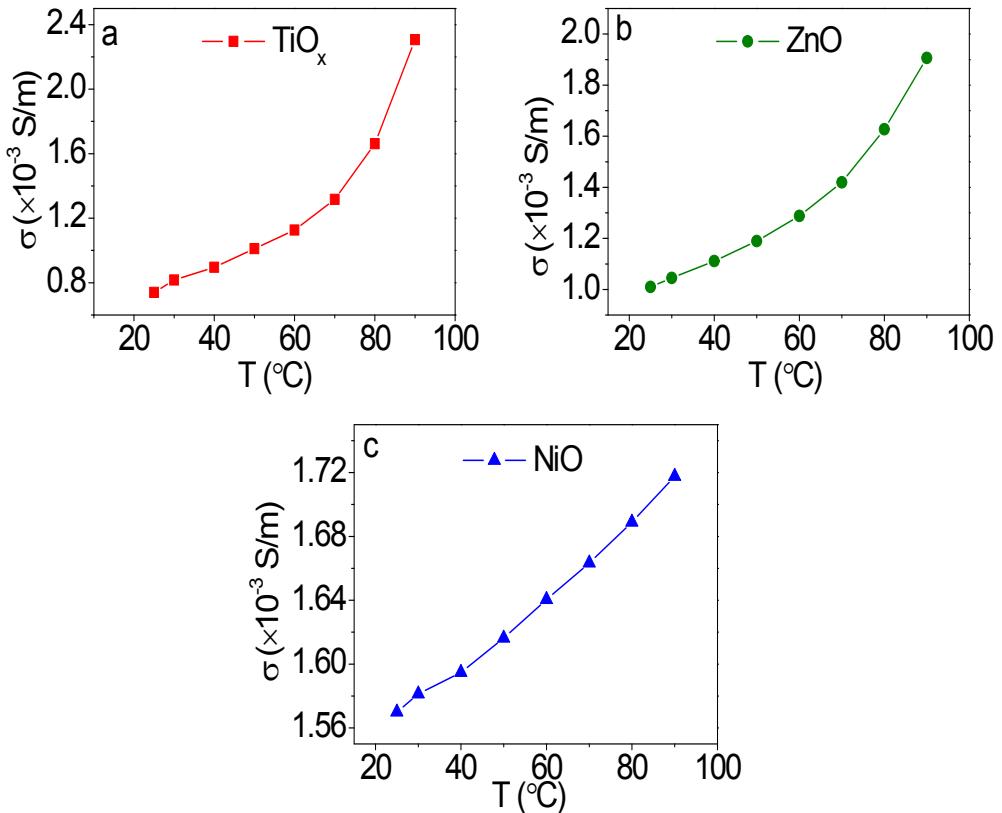


Figure S4: The temperature dependence of electrical conductivity in the single-layer devices: (a) ITO/TiO<sub>x</sub>/Al, (b) ITO/ZnO/Al, (c) ITO/NiO/Al.

#### 5. The calculated power factor of C<sub>60</sub> devices

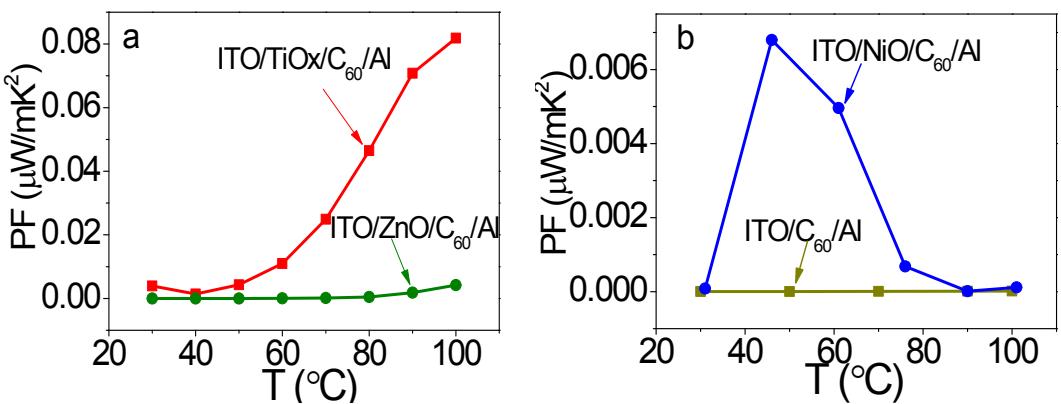


Figure S5: the calculated power factor of devices at different temperature: (a) ITO/TiO<sub>x</sub>/C<sub>60</sub>/Al and ITO/ZnO/C<sub>60</sub>/Al, (b) ITO/TiO<sub>x</sub>/C<sub>60</sub>/Al and ITO/C<sub>60</sub>/Al.

**Table 1**

<b>DEVICE</b>	$\frac{V_0}{V_T}$ (AT=30°C)	$\frac{V_0}{V_T}$ (AT=45°C)	$\frac{V_0}{V_T}$ (AT=60°C)
ITO/C <sub>60</sub> /Al	3.3%	3%	1.8%
Al/C <sub>60</sub> /Al	4.3%	3.5%	2.8%
ITO/ZnO/Al	2.5%	1.8%	1.7%
ITO/TiO <sub>x</sub> /Al	1.8%	1.6%	2.1%
ITO/NiO/Al	2.7%	2.5%	1.8%
ITO/ZnO/C <sub>60</sub> /Al	4.7%	3.4%	2.9%
ITO/TiO <sub>x</sub> /C <sub>60</sub> /Al	5.8%	4.8%	6.3%
ITO/NiO/C <sub>60</sub> /Al	3.7%	3.1%	4.9%

Table 1: The percentage of  $\frac{V_0}{V_T}$  for different devices at the average temperature of 30°C, 45°C, and 60°C, where the  $V_0$  and  $V_T$  are the measured voltage signals between the two electrodes of the devices measured without and with temperature difference, and AT is average temperature of the two electrodes.

60°C, where the  $V_0$  and  $V_T$  are the measured voltage signals between the two electrodes of the devices measured without and with temperature difference, and AT is average temperature of the two electrodes.